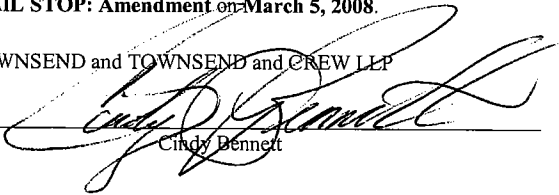


I hereby certify that this correspondence is being filed via
EFS-Web with the United States Patent and Trademark Office
MAIL STOP: Amendment on March 5, 2008.

PATENT
Attorney Docket No.: 16301M-021300US
Client Ref. No.: AM2119/PCT

TOWNSEND and TOWNSEND and CREW LLP

By:


Cindy Bennett

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of:

Karl Littau et al.

Application No.: 08/893,917

Filed: July 11, 1997

For: REMOTE PLASMA CLEANING SOURCE
HAVING REDUCED REACTIVITY WITH
A SUBSTRATE PROCESSING CHAMBER

Customer No.: 57385

Confirmation No. 8435

Examiner: Rudy Zervigon

Technology Center/Art Unit: 1763

AMENDMENT

MAIL STOP: AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

This paper is filed in response to the Office Action mailed September 5, 2007 (the "Office Action"). A three-month extension of time is also filed herewith, therefore rendering this response timely. In response to the Office Action, please enter the following amendments and remarks:

Amendments to the Claims are reflected in the listing of claims which begins on page 2 of this paper.

Remarks begin on page 6 of this paper.